



# Ultrathin-Layer Chromatography on Nanoengineered Thin Films

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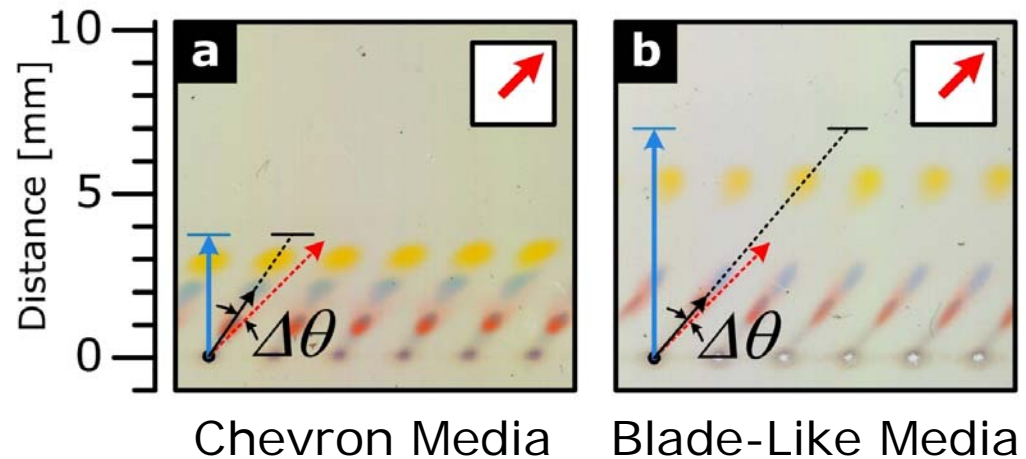


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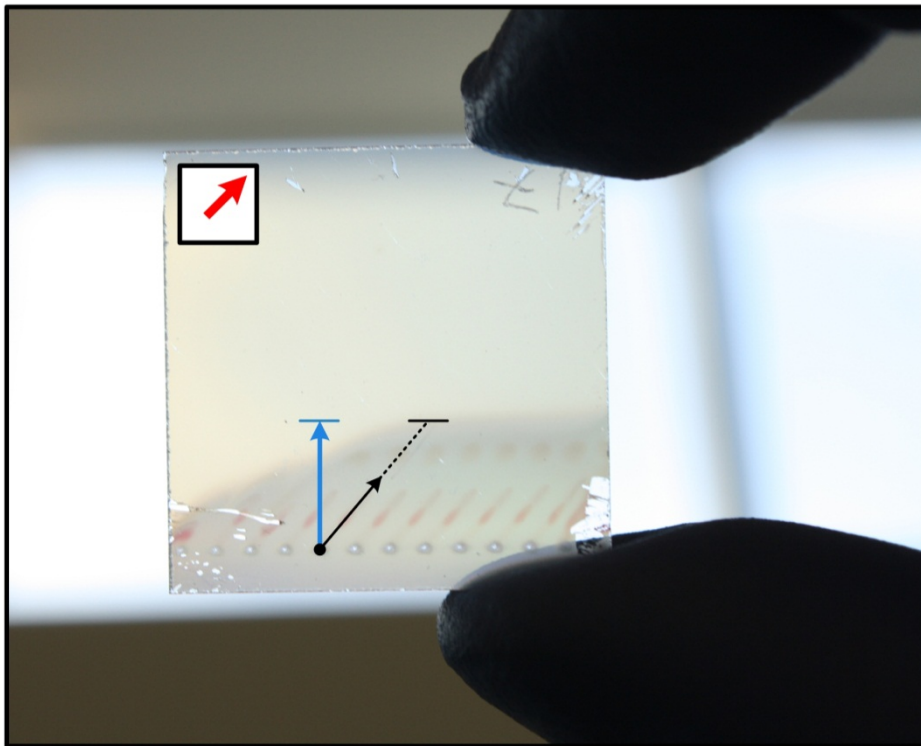
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## Overview



Diagonal dye separation pattern on an anisotropic ultrathin-layer chromatography plate fabricated using glancing angle deposition

Figure from S.R. Jim *et al.*, *Anal. Chem.* (2010).

- Higher performance with nanostructuring
- Glancing angle deposition (GLAD)
- GLAD ultrathin-layer chromatography (UTLC) microstructures
- Channel features in anisotropic GLAD UTLC media and their effects on elution
- Final thoughts



## Higher Performance with Nanostructuring

Stationary Phase Layer Properties	TLC <sup>1,2</sup> (particles, silica gel 60)	HPTLC <sup>1,2</sup> (particles, silica gel 60)	UTLC <sup>1-3</sup> (monolithic, silica gel)	GLAD UTLC <sup>4-7</sup> (columnar SiO <sub>2</sub> )
Typical Thickness (μm)	100 – 250	100 – 200	10	4.5 – 5
“Characteristic” Size (μm)	10 – 12 (mean particle size)	4 – 6 (mean particle size)	1 – 2 (macropore size)	0.1 – 0.8 (intercolumn void)
Pore Size (Å)	60	60	30 – 40	20 – 40
Specific Surface Area (m <sup>2</sup> g <sup>-1</sup> )	520	480 – 540	~ 350	~ 450
Representative Elutions	TLC <sup>1-3</sup>	HTLC <sup>1,2</sup>	UTLC <sup>1-3</sup>	GLAD UTLC <sup>4,5</sup>
Development Time (s)	> 900	> 180	60 – 360	< 90
Development Distance (mm)	70 – 150	30 – 70	10 – 30	10 – 14
Limit of Detection (ng, absorption)	1 – 5	0.1 – 0.5	0.5	< 10
Theoretical Plate Height (μm)	30 – 75	12 – 25	80 <sup>3</sup>	12 – 30

<sup>1</sup> S.K. Poole and C.F. Poole, *J. Chromatogr. A.* (2011); <sup>2</sup> ChromBook 2008|09, Merck KGaA, Darmstadt, Germany (2008);

<sup>3</sup> H.E. Hauck and M. Schulz, *J. Chromatogr. Sci.* (2002); <sup>4</sup> S.R. Jim *et al.*, *Anal. Chem.* (2010); <sup>5</sup> A.J. Oko *et al.*, *J. Chromatogr. A.* (2011); <sup>6</sup> K.M. Krause *et al.*, *Langmuir* (2010); <sup>7</sup> K.M. Krause *et al.*, *Microporous Mesoporous Mater.* (2011).



# Glancing Angle Deposition (GLAD) and UTLC Microstructures

*Shadowing and Sculpting*

*Architectures, Advantages, and Applications*

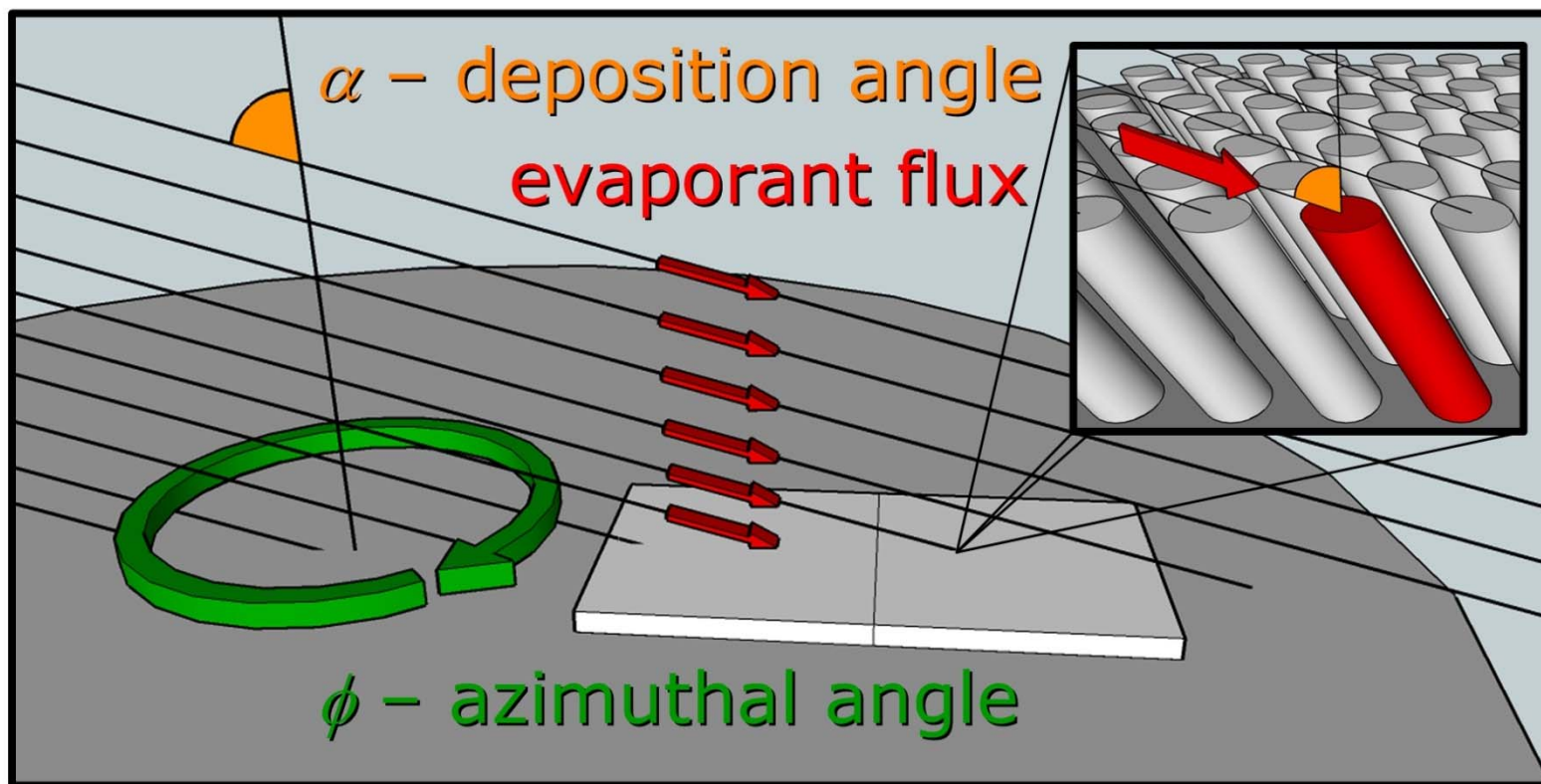
*GLAD Microstructures and Elution*

*Channel Features in Anisotropic Media*

*Migration in Anisotropic Microstructures*



## Shadowing and Sculpting



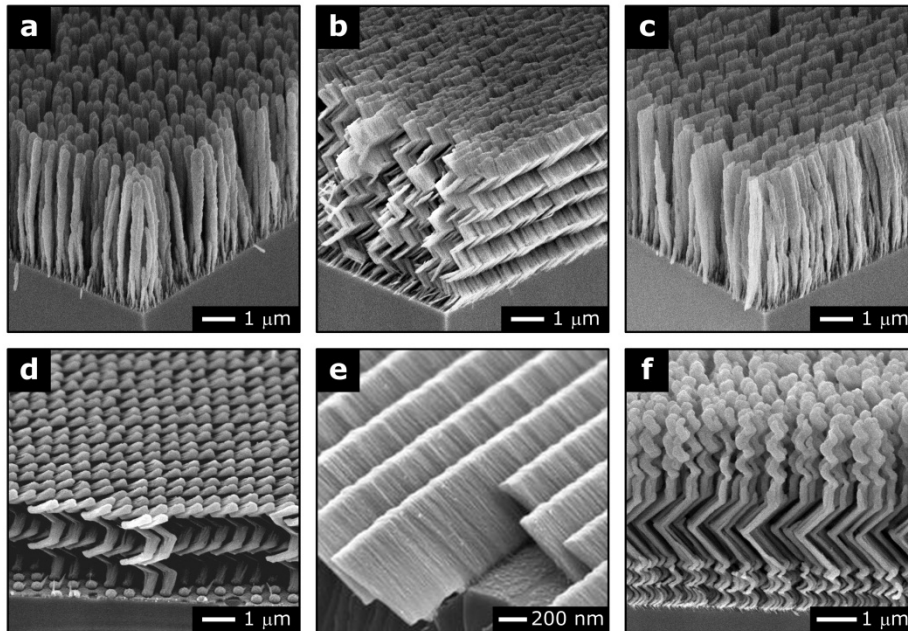
Glancing angle deposition couples self-shadowing with substrate motion control to sculpt columnar thin films of useful morphologies.

Figure from S.R. Jim *et al.*, *Anal. Chem.* (2010).



# Architectures, Advantages, and Applications

Representative scanning electron micrographs of GLAD morphologies



(a) Vertical post, (b) chevron, (c) blade-like, (d) helical, (e) nanoribbon, and (f) hybrid structures.

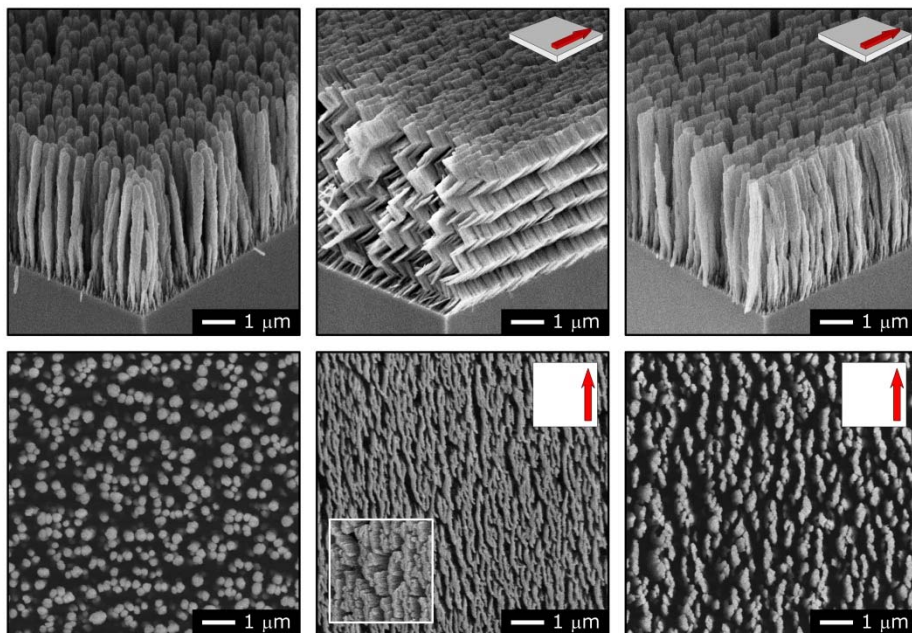
Images reproduced from (a-c) S.R. Jim *et al.*, *Anal. Chem.* (2010); (d) P.C.P Hrudey *et al.*, *Proc. SPIE* (2005); (e) J.J. Steele *et al.*, *J. Mater. Sci.: Mater. Electron.* (2007); (f) A.C. van Popta *et al.*, *Proc. SPIE* (2004).

- *Key Capabilities*
  - Excellent control over porosity and architecture
  - Variety of materials
  - Patented single-step technology compatible with microfabrication
- *Applications*
  - Rapid relative humidity sensors
  - Optical and photovoltaic devices
  - Planar chromatography



## GLAD Microstructures and Elution

Micrographs of macroporous GLAD thin film separation media

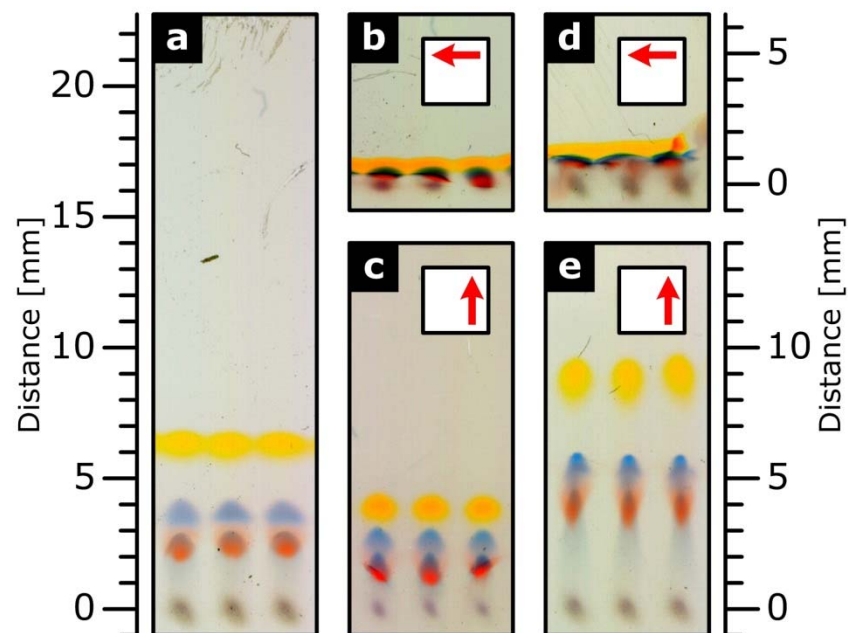


Vertical Post  
(Isotropic)

Chevron  
(Anisotropic)

Blade-Like  
(Anisotropic)

Scanned images of developed GLAD UTLC plates



Vertical Post  
(Isotropic)

Chevron  
(Anisotropic)

Blade-Like  
(Anisotropic)

Figures modified from S.R. Jim *et al.*, *Anal. Chem.* (2010).

## Channel Features in Anisotropic Media

- *Development track deviation angle ( $\Delta\theta$ ) as a measure of the "extent of anisotropy":*

$$\Delta\theta = \theta_C - \theta_T \quad (1)$$

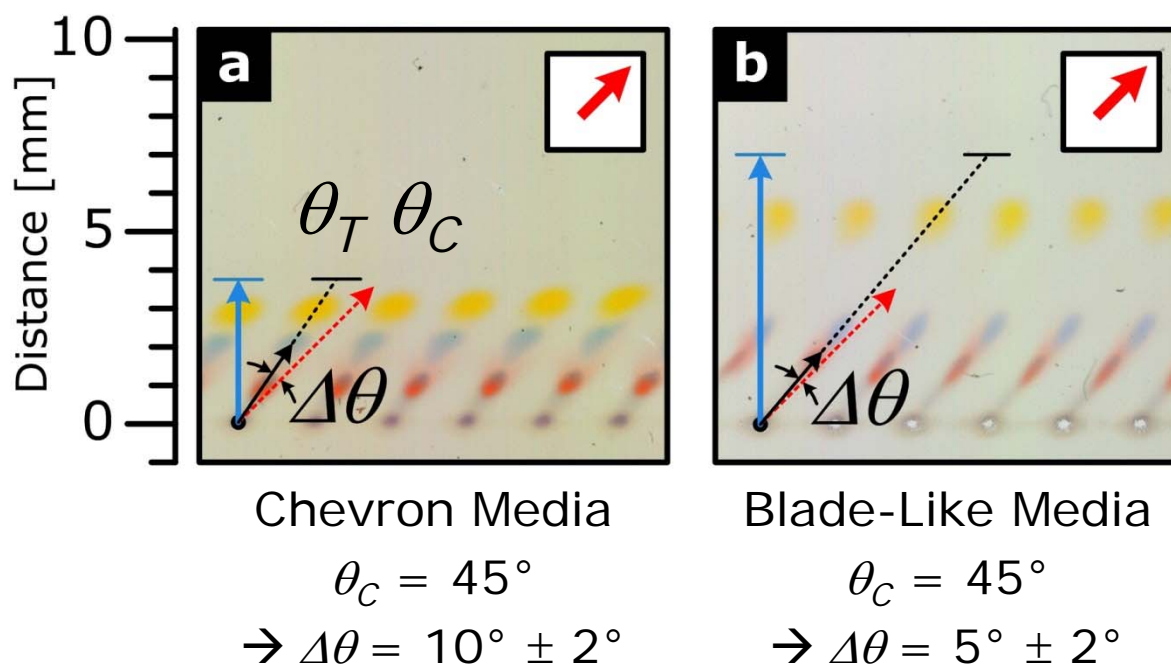
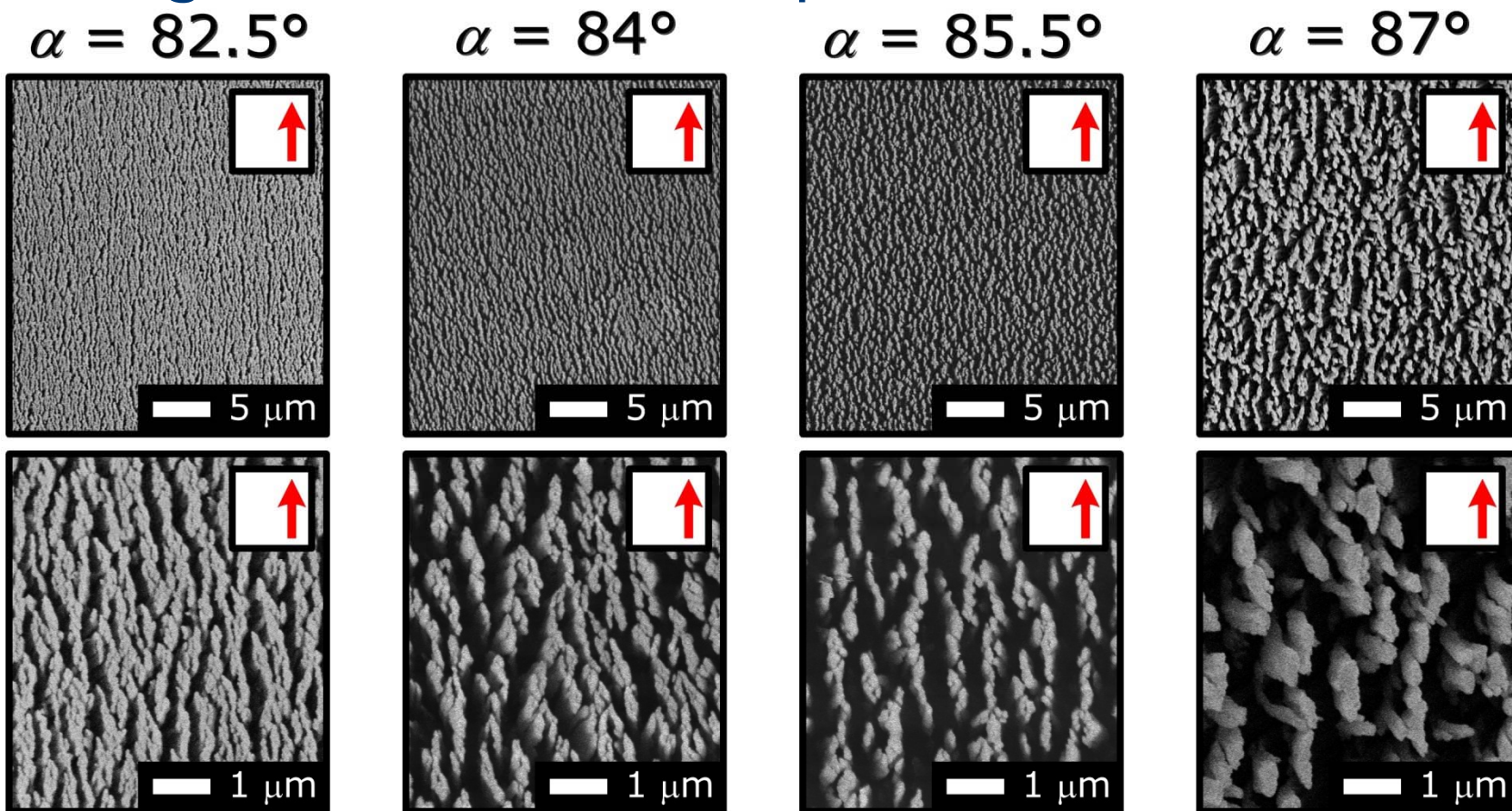


Figure modified from S.R. Jim *et al.*, *Anal. Chem.* (2010).





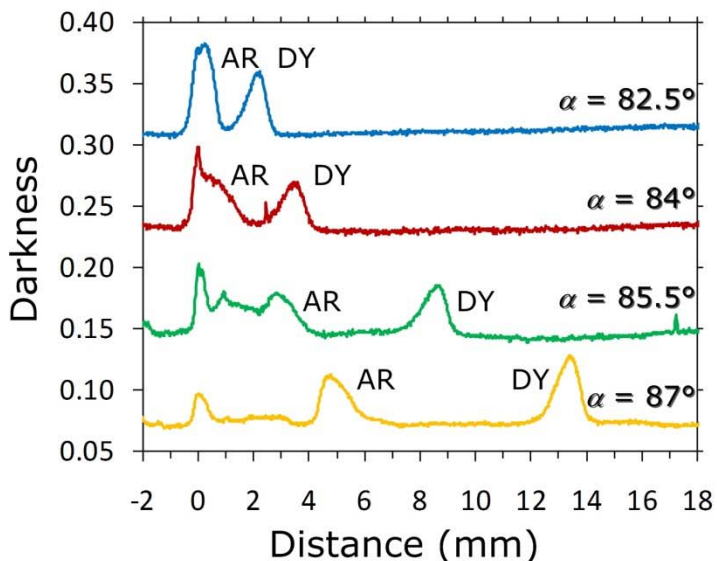
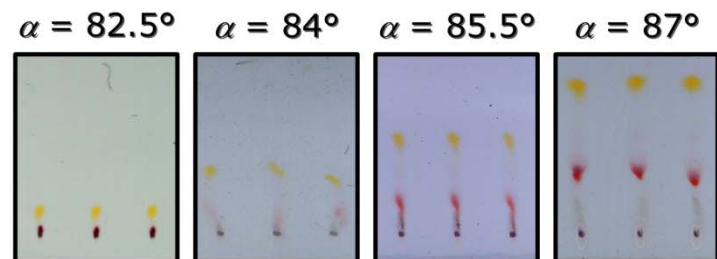
## Migration in Anisotropic Microstructures



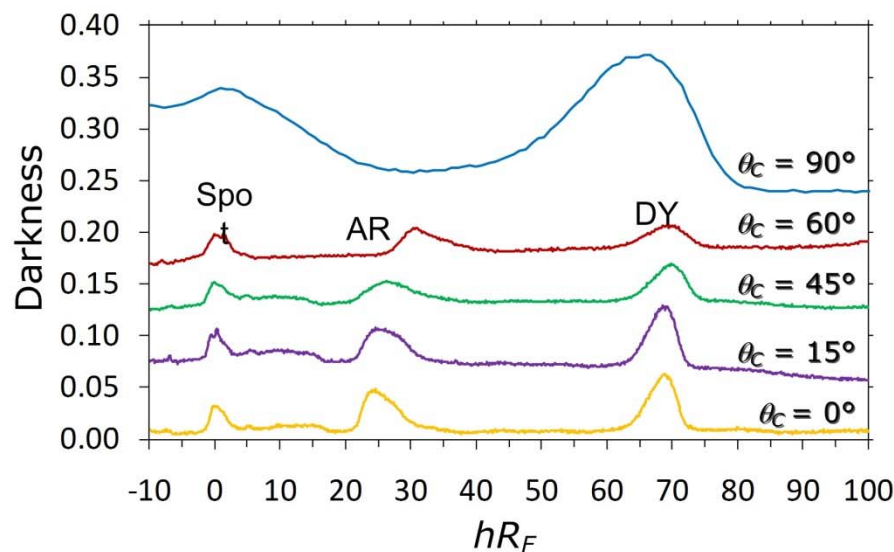
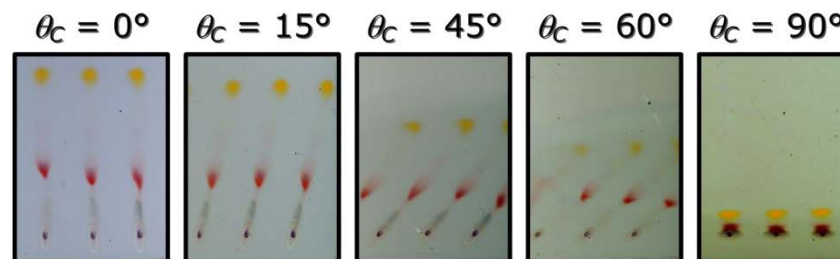
Low and high magnification top view SEM micrographs of  $\sim 5 \mu\text{m}$  thick  $\text{SiO}_2$  blade-like films fabricated with varied deposition angle ( $\alpha$ )

Figure modified from A.J. Oko *et al.*, *Anal. Chem.* (2011).

# Migration in Anisotropic Microstructures



Along-channel ( $\theta_c = 0^\circ$ ) chromatograms for GLAD UTLC plates of varied porosity (varied deposition angle,  $\alpha$ )



Chromatograms for  $\alpha = 87^\circ$  blade-like plate with channels oriented at varied angles ( $\theta_c$ )

Figures modified from A.J. Oko *et al.*, *Anal. Chem.* (2011).



# Final Thoughts

*Conclusions*

*Acknowledgements*

*Further readings on the GLAD technique and on GLAD UTLC*



## Conclusions

- Planar chromatography performance improves with stationary phase microstructure engineering.
- GLAD provides excellent control over the porosity and architecture of columnar UTLC microstructures.
- Anisotropic GLAD UTLC media exhibit channel features that strongly influence analyte migration velocities, separation track orientations, and spot broadening.
- Ongoing research aims to combine the benefits of anisotropic media with post-processing and better-suited chromatography instrumentation to produce a high-performance GLAD UTLC system.



## Acknowledgements



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**CORE**



**micralyne**



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de nanotechnologie



Alberta  
Innovates  
Technology  
Futures

University of Alberta



**Nano  
Fab**

A Micro-Machining &  
Nanofabrication Facility

- GLAD Lab Group (including the other members of the GLAD UTLC team: Z. Wang and L. Bezuidenhout)
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- SEM expertise of G. Braybrook and D.-A. Rollings (U of A EAS SEM Lab); J. Siewert (GLAD Lab)
- RIE help from S. Munro (NanoFab)
- Custom apparatus fabrication (U of A ECE Machine Shop)



### *Further reading on GLAD UTLC*

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1. A.J. Oko, S.R. Jim, M.T. Taschuk, M.J. Brett, "Analyte migration in anisotropic nanostructured ultrathin-layer chromatography media", *Journal of Chromatography A* 1218(19), 2661-2667 (2011).
  2. S.R. Jim, M.T. Taschuk, G.E. Morlock, L.W. Bezuidenhout, W. Schwack, M.J. Brett, "Engineered Anisotropic Microstructures for Ultrathin-Layer Chromatography", *Analytical Chemistry* 82(12), 5349–5356 (2010).
  3. G.E. Morlock, C. Oellig, L.W. Bezuidenhout, M.J. Brett, W. Schwack, "Miniaturized planar chromatography using office peripherals", *Analytical Chemistry* 82(7), 2940-2946 (2010).
  4. L.W. Bezuidenhout, M.J. Brett, "Ultrathin layer chromatography on nanostructured thin films", *Journal of Chromatography A* 1183(1-2), 179-185 (2008).
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### *Further reading on the GLAD technique and applications*

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1. M.T. Taschuk, M.M. Hawkeye, M.J. Brett, "Glancing Angle Deposition," *Handbook of Deposition Technologies for Films and Coatings: Science, Applications and Technology*, P. Martin (ed.), Oxford, United Kingdom: William Andrew (Elsevier), 621-678 (2010).
  2. M.J. Brett, M.M. Hawkeye, "New materials at a glance," *Science* 319(5867), 1192-1193 (2008).
  3. M.M. Hawkeye, M.J. Brett, "Glancing angle deposition: Fabrication, properties, and applications of micro- and nanostructured thin films," *Journal of Vacuum Science & Technology A: Vacuum, Surfaces, and Films* 25(5), 1317-1335 (2007).
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